

Effect of an Adjustable Admittance on the Macroscopic Energy Levels of a Current Biased Josephson Junction

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Abstract

We have observed the set of macroscopic quantum tunneling levels of an S-I-S junction in a current biased Josephson junction shunted by a resistor, and also when several admittances were added in series. By studying the dependence on current, we located exactly the energy structure between successive levels, and observed a current hysteresis if the current is symmetrical in the positive and other current bias cases.

1. Introduction

Electronic circuits based on semiconductor devices always behave classically in the sense that current flowing in them are macroscopic variables obeying classical equations. The words "quantum phenomena" only mean that the devices are based on the microscopic quantum behavior of individual electrons in a solid-state device. For example, the negative slope of the voltage to current relationship originates in the quantum mechanical scattering of electrons across the junction. However, at the macroscopic level, the resulting properties of the device are in accord with an adequate low dimension theory explained in purely classical terms once the voltage to current relationship is known.

In recent years, by means of experiments [1–4] involving Josephson junctions at dilution refrigerator temperatures, have demonstrated these macroscopic electrical variables behave quantum-mechanically. In the case of the conventional junction, the macroscopic variable is the phase difference ϕ between the superconducting order parameters on either side of the junction. The observations show that the junction behaves as a single entity, as if the charge of an electron is replaced by the charge of a Cooper pair, the phase difference ϕ playing the role of the electron position x . The junction is equivalent to the system consisting of a particle of mass m^* and charge $2e$ moving in a potential $V(\phi) = -\frac{2e}{\hbar} \int \phi d\phi + (2e)^2/\phi^2$, where \hbar and e are the junction critical current and capacitance, ϕ is the bias current and $\hbar/2e$ is the quantum Φ_0 . The voltage across the junction is proportional to the velocity of the particle. The zero-voltage state of the junction corresponds to the confinement of the particle in a well of the total wall of the total critical potential and is analogous to the bound state of the electron in the Coulomb potential of the nucleus. When the particle escapes from the minimum state it rapidly drops the potential and a voltage appears across the junction. The structure of the resulting I - V characteristic curve is analogous to the structure of the ionization of the atom.

In the current conditions of the experiment, the critical current $I_c = 20$, it was clear to see that the potential barrier of the particle escapes is an energy gap phenomenon. This results from the minimum energy $E(\phi) = E_0(1 - \cos \phi)$ and oscillation frequency ω of the barrier of the well $\omega_0 = (2e/\hbar C)^{-1/2}$, where $E_0 = \frac{1}{2} I_c \Phi_0$ and $C = (4\pi \epsilon_0 \Phi_0^2 / 4e^2) \phi^{-2} = \frac{1}{2} I_c^{-1} \Phi_0^2$ (see fig. 1). A previous experiment has demonstrated the existence of quasienergy levels [5] by measuring the enhancement of the escape rate in presence of a microwave irradiation that induces transitions between levels. Theoretical calculations of energy level positions and widths that agree qualitatively with the coupling of the junction with an external circuit are in quantitative agreement with the experimental analysis [6].

These calculations are based on a central problem in atomic physics: the modification of the energy levels of an atom induced by its coupling with the radiation field. For the current biased junction, the role of the field is played by the microwave-driven multi-photon charging process. In the aforementioned experiment this effect behaved as a capacitor, which simply renormalized the junction capacitance, in parallel with a resistor. In atomic physics this system corresponds to the far resonance.

A similar objective is the use of the counterfactual selective spin-flipping fields. This case has recently been realized experimentally in the investigation of the stability of the energy levels of an atom placed in an electromagnetic [7]. We have built the quantum circuit [8] using all these ingredients: an Josephson junction in a microwave resonating circuit that can be varied in time. We report in this paper the observation of the modification of the shift and width of the junction energy levels induced by the existence of the resonating mode frequency of the circuit.

2. Experimental apparatus and procedure

A $I_c = 10$ pA, $\Phi_0 = 100$ fF, Φ_0 SQUID current biased junction was prepared on a Si wafer using standard e-beam lithography and passivation techniques. The junction chip, 1×1 mm, was then mounted at the end of a superconductor line connected from a straight copper printed-circuit board. Electrical connections between the line and the junction were made with indium pads. A microwave steering block, shown in the following as "the head", was placed on the superconductor at a distance L from the indium pads. It defines a section of free line loaded by a series of loop line of lower characteristic impedance.

Measurements at microwave frequencies with a network analyzer indicate that signal from the junction, the input line with the head can be considered as an ideal transmission

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Fig. 1. Total potential energy as a function of the junction coordinate x in presence of an external magnetic field and an applied bias current I . The energy levels are quantized energy levels in the well can be obtained by solving Schrödinger equation for the potential function.

size of dielectric impedance $Z_d = 75 \pm 5\Omega$ and length $l = L + 2l$ terminated by a resistance $Z = 51 \pm 30\Omega$ (see Fig. 2). The total length $2l$ terminated by $Z = 51 \pm 4\text{mm}$, represents the length of the superconductor junction step and the dimensions of the dielectric film due to the impedance discontinuities at junction ends and at the load. The intrinsic admittance Y_0 was calculated for the superconductor junction as $Y_0 = 1.4 \pm 4.1 \times 10^{-4}\text{mho}$. The assembly was enclosed in a radiation tight copper enclosure and thermally anchored to the cooling chamber of a dilution refrigerator. The load position z was adjusted by means of a screw which was pulled from the top of the cryostat and was connected to a micrometer screwdriver position sensor. The junction was die-cast, sealed using the laser seal wire combination of the cryostat line. An insulating coating of the microwave shielding lead around the junction, which helps to shield it from microwave stray fields, was deposited in a vacuum chamber. In addition to the die film, the junction was subjected to a microwave current source that consisted of an operational amplifier which brought within 1 μm of the junction and connected through the copper shield to a microwave generator. Electrical connections to room temperature electronics were made through a series of filters that prevented thermal and particle noise from reaching the junction and which have been described previously [9].

The temperature of the copper enclosure was determined using a combination of a platinum resistance thermometer, a ^{13}C acetone thermometer and a series of NBS fixed point cells. The lowest measured temperature is 4 mK. The accuracy of the temperature scale and distribution of a typical case level of overall noise in the copper shield was checked by using a second junction with a different area and superconductor film that it stayed in the thermal regime even at the lowest temperature.

We measured the super loss of the junction out of the zero-current state in a collection of die film current, without using microwave insulation, using the technique of Fisher and Chakrabarty [11]. The microwave power P_{mic} was adjusted to give a relative increase $\delta = P_{\text{mic}} - P_{\text{mic}}(0)/P_{\text{mic}}(0)$ of the super loss δ with fixed energy $\omega = 2$ (value of 100) was in the range 10^3 to $10^4\%$. The current typically $I = 10^3$ existing state. After the junction had returned to the



Fig. 2. Microwave circuit above junction barrier is used to do zero-current state. The dielectric impedance Z_d and length $l = L + 2l$ terminated by a resistance $Z = 51 \pm 30\Omega$ (see Fig. 2). The total length $2l$ terminated by $Z = 51 \pm 4\text{mm}$, represents the length of the superconductor junction step and the dimensions of the dielectric film due to the impedance discontinuities at junction ends and at the load.

voltage state, the bias current was turned off within 10 μs . We checked that the elapsed time before the next switching event was sufficient for any faster processes than occurred in the dielectric case at lower magnetic strengths. We changed the position of the lead by steps of 1 or $\sqrt{2}$ mm. In each step, the bias generated by features of the block on the cryostat line raised the temperature of the cooling chamber to about 10 mK and we had to wait for one hour before the data collection could be resumed at the lower temperature.

3. Results and Discussion

Super loss measurements performed in the dielectric case showed in addition [4] very good agreement with theory predictions (see [9]). These measurements showed a distribution of $g = \text{Im}(Z) / \text{Re}(Z)$ and $C = 0.3 \pm 0.1\%$. During these measurements the position of the lead was kept approximately $z = 0$ mm to which the model of the junction described by a smoothly frequency-dependent admittance is valid. When z was varied we observed the oscillations of the measured super loss predicted by Fisher and Chakrabarty [9]. These observations provide an independent determination of the dielectric film thickness l and the frequency, and will be described in forthcoming publications [4].

At frequencies below 100 GHz, with frequency scale with unit in picoseconds and the super loss in the absence of microwave losses temperature independent, with a value in good agreement with predictions for microwave quantum tunneling [9]. In the presence of microwave loss, which the super loss to be measured, enhanced super loss in the absence of microwave loss when the microwave current energy matches the spacing between the ground state and the first excited state. Note that the increasing size of the excited state is three orders of magnitude greater than one of the ground state so that a relatively small population of the excited state leads to a large increase in the excitation. We detect this increase by varying the energy, corresponding with the microwave while keeping the microwave frequency fixed. Figure 7 illustrates the results for $J_c = 1000$ and a microwave frequency of 10-20 GHz. We define the microwave current I_{mic} as the current corresponding to the maximum of the microwave curve, in Fig. 4 we plot I_{mic} as a function of the load position z for three microwave frequencies. We showed that, at constant microwave insulation frequency, as the length increases the microwave current is less difficult to



Fig. 1. Measured current-voltage characteristics of the junction $L = 1.5 \mu\text{m}$. The resonance frequency $\omega_0 = 1.5 \text{ THz}$ (corresponding to $L = 1.5 \mu\text{m}$) is used here as a scale for the current-voltage curves. The solid line is the theoretical calculation for the current-voltage characteristics of the junction. The dots are the experimental data.

lower values. A broadening of the resonance curve occurs during the increasing trend. Thus, when the length corresponding to a half wavelength of the radiation frequency is reached, L_{res} makes a sudden change to higher values and this means an increased trend. This same behavior is repeated as the length corresponding to one wavelength of the radiation frequency. When the corresponding half-wavelength is throughout the resonance of the junction becomes smaller, this is why, for each frequency, L_{res} is not plotted at certain positions.

When we take insight on this behavior in the following way: when the plasma frequency ω_p is not too close to the natural resonance frequency of the line, the coupling of the positive-to-negative modes through the nonlinear reflective properties of the junction $\omega = \omega' + \omega_c$, $\text{Re}(\omega') \approx \omega_0$ where ω_0 is the resonance of the line caused by the junction of



Fig. 2. Measured current-voltage characteristics of the junction-frequency $\omega_p = 1.5 \text{ THz}$ (solid line), $\omega_p = 1.4 \text{ THz}$ (dotted line) and $\omega_p = 1.3 \text{ THz}$ (dashed line) are plotted for the same bias current as in the resonance frequency $\omega_0 = 1.5 \text{ THz}$.



Fig. 3. (a) Schematic model of the junction-graphene structure for which the energy of the incident microwave is in the range of a few electron volt (eV). (b) The coupling between the $\omega = \omega'$ submode of the plasma and the frequency of the radiation ω (see notes in the text) causing optical a periodic resonance of the plasma structure in the nonlinear regime. (c) Dependence of the current I (normalized to the zero-current value) on the current I_0 for each bias and the corresponding resonance frequencies.

frequency ω . Here we neglect the difference of order 10% between ω_0 and the resonance frequency ω_0' between the ground state and the first excited state. As the length is increased the imaginary part of the microwave admittance of the plasma frequency is considered a periodic function, the period being the half wavelength of the plasma frequency ω_0 . Consequently I_{res} , which is generally the current at which the electron current will increase with the effective impedance at the radiation frequency, will vary periodically with the position of the bias.

However, this simple model cannot explain an interesting feature of the data presented in Fig. 4. As pointed to the vicinity of the wavelength of the plasma frequency two resonances corresponding to two distinct resonance frequencies can be found at the same current, i.e. the curves $I_{\text{res}}(I_0)$ cross one another. This means that at a fixed current, there is no longer only one resonance between the junction ground state and the first excited state but two resonances in a split excited state. This can be explained by considering the junction and the line as separate entities for forming a global system (junction + line) (see Fig. 5). In $\omega = 2\omega_0$, ω_0 if one ignores the coupling between the junction and the line, the first excited state of the junction coincides with the second-order mode of the overmode of the line. This phenomenon leads into width W due to the same non-linear resonance condition and is coupled to the junction near half-wavelength. In an analogous manner the coupling nonlinear resonance must be considered $(2L + W)/4$, perturbation theory is valid and the junction state simply separates with $\omega = W/2 = 2W/4 = W/2$, $2L + W/4 = W/4$, perturbation theory is no longer valid and the line loses their identity. One finds instead two levels of equal width $\omega = W/2$ separated by $\Delta\omega = (W/2 - 2LW/4)^2$. The condition for the breakdown of perturbation theory can be expressed in terms of dimensional parameters of the junction (non-linear current I_{NL}) and the breakdown current I_0 $I_{\text{NL}} > I_0 \text{Re}(\omega_0) \text{Re}(\omega_0') \text{Re}(\omega_0'') = I_0 \text{Re}(\omega_0) - 0.54 I_0 C + 0.81 I_0 W$ where $C = (W/4)^2$. This condition is satisfied for the parameters of our experiment.

4. Conclusions

Our results for the combination of the energy levels of the zero voltage state of a quantum tunnel diode-graphene junction induced by the coupling with a transmission line show that

probabilistic theory cannot account for all the features of the data. A probabilistic analysis provides qualitative understanding of the shifts and widths of the distributions of the positive modulus frequency in the two cases for the repeated experiments of the two different adhesion temperatures events, or "solidification" of the state of the junction and the formation. These results sometimes evidence that the modulus is present throughout network composed of the junction and its increase during curing time to be treated as a whole system-mechanical system.

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